

Notic of References Cited	Application/Control No. 09/878,265		Applicant(s)/Patent Under Reexamination OGURA ET AL.	
	Examiner Alvin J Grant		Art Unit 3723	Page 1 of 1

U.S. PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
	A	US-5,634,955	06-1997	Araujo et al.	65/17.2
	B	US-6,563,079	05-2003	Umetsu et al.	219/121.71
	C	US-			
	D	US-			
	E	US-			
	F	US-			
	G	US-			
	H	US-			
	I	US-			
	J	US-			
	K	US-			
	L	US-			
	M	US-			

FOREIGN PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N					
	O					
	P					
	Q					
	R					
	S					
	T					

NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	Rudolph P, Bonse J, Kruger J, Kautek W; Femtosecond-and nanosecond-pulse laser ablation of bariumalumoborosilicate glass; 28 December 1999; Applied Physics A Materials Science & Processing: PP S763-S766
	V	
	W	
	X	

*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.

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